

Electronic Patent Application Fee Transmittal

| | | | | |
|---|---|-----------------|---------------|-----------------------------|
| Application Number: | 10589681 | | | |
| Filing Date: | 16-Aug-2006 | | | |
| Title of Invention: | Polymer Compound, Photoresist Composition Including the Polymer Compound, and Resist Pattern Formation Method | | | |
| First Named Inventor/Applicant Name: | Toshiyuki Ogata | | | |
| Filer: | Neil S. Bartfeld | | | |
| Attorney Docket Number: | SHIGA7.054APC | | | |
| Filed as Large Entity | | | | |
| U.S. National Stage under 35 USC 371 Filing Fees | | | | |
| Description | Fee Code | Quantity | Amount | Sub-Total in USD(\$) |
| Basic Filing: | | | | |
| Pages: | | | | |
| Claims: | | | | |
| Claims in excess of 20 | 1615 | 2 | 50 | 100 |
| Independent claims in excess of 3 | 1614 | 4 | 210 | 840 |
| Multiple dependent claims | 1616 | 1 | 370 | 370 |
| Miscellaneous-Filing: | | | | |
| Petition: | | | | |
| Patent-Appeals-and-Interference: | | | | |

| Description | Fee Code | Quantity | Amount | Sub-Total in USD(\$) |
|-----------------------------------|----------|----------|--------|----------------------|
| Post-Allowance-and-Post-Issuance: | | | | |
| Extension-of-Time: | | | | |
| Miscellaneous: | | | | |
| Total in USD (\$) | | | | 1310 |